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Interpretation of NH3-TPD Profiles from Cu-CHA Using First-Principles Calculations

Lin Chen1 · Ton V. W. Janssens2 · Magnus Skoglundh1 · Henrik Grönbeck1

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Abstract
Temperature-programmed desorption (TPD) with ammonia is widely used for zeolite characterization revealing information on acidity and adsorption sites. The interpretation of TPD measurements is, however, often challenging. One example is the NH3-TPD profile from Cu-chabazite (Cu-CHA) which generally is deconvoluted in three peaks with contributions from NH3 on Lewis acid sites, copper sites and Brønsted acid sites. Here, we use density functional theory calculations combined with kinetic simulations to analyze this case. We find a large number of possible species, giving rise to overlapping features in the NH3-TPD. The experimental low-temperature peak (below 200 °C) is assigned to NH3 desorption from Lewis acid sites together with NH3 desorption from a [Cu(II)(OH)(NH3)3]⁺ complex. The intermediate-temperature peak (250–350 °C) is attributed to decomposition of a linear [Cu(I)(NH3)2]⁺ complex and a residual from [Cu(II)(OH)(NH3)3]⁺. The high-temperature peak is predicted to have contributions from Brønsted acid sites (NH4⁺), [Cu(I)NH3]⁺ and [Cu(II)(NH3)4]²⁺. The present work shows that NH3-TPD from Cu-CHA can be reconciled with copper complexes as NH3 storage sites.

Keywords NH3-TPD · Zeolites · Cu-CHA · Acidity

1 Introduction
Temperature-programmed desorption (TPD) is widely used for characterization of heterogeneous catalysts. The method is straightforward and based on the measurement of the desorption profile of a pre-adsorbed probe molecule during controlled heating. For zeolites and oxide surfaces, NH3-TPD is generally used to measure the amount of acid sites together with the acid strength [1, 2]. Despite its simplicity, the interpretation of TPD profiles is often hampered by limited knowledge on the active sites, sample heterogeneity and coverage dependent adsorbate–adsorbate interactions. Due to these complications, TPD measurements are commonly used merely as a catalyst signature of acidity rather than a means to obtain site-specific information. One example is NH3-TPD profiles from zeolites functionalized with copper ions.

Zeolites exchanged with copper ions are efficient catalysts for selective catalytic reduction of NOx with ammonia (NH3-SCR), which is the basis of the current technology for the abatement of NOx emission from diesel engines [3, 4]. In particular, copper-exchanged zeolites and zeotypes with the small-pore chabazite framework structure (Cu-CHA) is the state-of-the-art catalyst for NH3-SCR which combines a good performance in the temperature range 200–550 °C with a high hydrothermal stability [5–7]. The NH3-TPD profile of Cu-CHA is characterized by three desorption peaks [8–17]; a low-temperature peak below 200 °C, an intermediate-temperature peak at 250–350 °C and a high-temperature peak at 400–500 °C.

The low-temperature peak is generally assigned to NH3 adsorbed to Lewis acid sites [8–13, 17] whereas the peak at 400–500 °C has been attributed to NH3 adsorbed on Brønsted acid sites. NH3 adsorbed at Cu-sites has been suggested to give rise to the intermediate-temperature peak at 250–350 °C [8–12]. An attempt to assign the peaks to specific Cu sites was made in Ref. [8] where the intermediate and high temperature peaks were attributed to Cu...
coordinated to the zeolite framework in 6- and 8-membered rings, respectively.

The understanding of the active sites in Cu-CHA during operating conditions has advanced during the recent years. Experimental as well as computational studies have shown that Cu\(^{+}\) is preferably solvated by two NH\(_3\) ligands forming a linear [Cu(I)(NH\(_3\))\(_2\)]\(^{+}\) complex under low-temperature NH\(_3\)-SCR conditions [18–24]. The [Cu(I)(NH\(_3\))\(_2\)]\(^{+}\) complex is mobile with low barriers for inter-cage diffusion and suggested to be important also for the solid-state ion-exchange reaction [25]. In addition to Cu\(^{+}\) species, Cu-CHA also contain solvated Cu\(^{2+}\) species in the form of [Cu(II)(NH\(_3\))\(_4\)]\(^{2+}\) or [Cu(II)(OH)(NH\(_3\))\(_3\)]\(^{+}\) [15, 18, 20].

The evidence of NH\(_3\)-solvated complexes under NH\(_3\)-SCR conditions should have consequences for the interpretation of NH\(_3\)-TPD profile from Cu-CHA. In particular, the desorbed NH\(_3\) should partly originate from NH\(_3\)-solvated Cu-complexes. In this study, density functional theory calculations in combination with kinetic simulations are used to elucidate the NH\(_3\)-TPD profile from Cu-CHA. We find that the experimental NH\(_3\)-TPD curves can be reconciled with NH\(_3\) desorbing from Lewis acid sites, solvated copper species and Brønsted acid sites. By simulating the NH\(_3\)-TPD curves based on the stability of different species as calculated by DFT, we obtain insights on the observed features of NH\(_3\)-TPD from Cu-CHA. Moreover, the identification of the decomposition temperature of [Cu(I)(NH\(_3\))\(_2\)]\(^{+}\) complexes provides information that elucidates the temperature dependent activity of the Cu-CHA catalyst, including the often observed decrease in NO conversion with increasing temperature.

2 Computational Methods

2.1 Density Functional Theory Calculations

Spin-polarised density functional theory calculations are performed with the Vienna Ab-Initio Simulation Package (VASP) [26–29].\(^1\) The Kohn–Sham orbitals are expanded with plane waves using an energy cut-off of 480 eV and the interaction between the valence electrons and the cores is described with the plane augmented wave (PAW) method [30, 31]. The number of valence electrons used in the calculations are 11 for Cu, 4 for Si, 3 for Al, 6 for O, 5 for N and 1 for H. The exchange-correlation functional is approximated with the PBE+cx van der Waals functional [32]. PBE+cx makes use of the vdw-DF [33] description, which provides an accurate description of binding energies of, for example, molecular dimers [32]. Structures are optimized with the conjugate gradient method and geometries are considered to be converged when the electronic energy difference between subsequent steps is smaller than 1 × 10\(^{-5}\) eV and the largest force is smaller than 3 × 10\(^{-2}\) eV/Å. The k-point sampling is restricted to the Γ point. The calculated energies are zero-point corrected and the harmonic vibrational frequencies are computed using a finite-difference approach.

The chabazite structure is modeled using a rhombohedral unit cell which includes 12 Si atoms in tetrahedral (T) positions. The optimized cell parameters are \(a, b, c = 9.42\) Å and \(α, β, γ = 94°\). The lattice parameters are kept fixed during the geometry relaxations.\(^2\) The Si/Al ratio is 11 and 5 when considering cationic and double cationic species, respectively. Both Si/Al ratios are within the common experimental range between 20 and 5 [20, 34–36]. To study the influence of complex and adsorbate concentration, calculations were performed also in a (2 × 2 × 2) super-cell increasing the Si/Al ratio by a factor of 8.

2.2 Evaluation of NH\(_3\)-TPD

The NH\(_3\) desorption profiles have been analyzed following Refs. [37, 38] taking readsorption into account. Consequently, the simulated process is:

\[
\text{NH}_3^* \xrightarrow{k_d} \text{NH}_3(g) + \star \tag{1}
\]

where \(\star\) denotes an adsorption site and NH\(_3\)(g) is ammonia in the gas phase. \(k_d\) and \(k_a\) are the desorption and adsorption rate constants, respectively. In the mean-field assumption, the time derivative of the NH\(_3\) coverage (\(θ\)) is given by:

\[
\frac{dθ}{dt} = k_a \frac{P_g}{P_0} (1 - θ) - k_d θ \tag{2}
\]

where \(P_g\) is the pressure of ammonia and \(P_0\) is the pressure at standard conditions. Using the ideal gas law, \(P_g\) can be written as \(RTC_g\) where \(R\) is the gas constant, \(T\) is the temperature and \(C_g\) is the ammonia concentration. The concentration can be calculated assuming equilibrium between the gaseous and adsorbed ammonia:

\[
C_g = \frac{θ}{1 - θ} \frac{P_0}{RT} K \tag{3}
\]

where \(K\) is the equilibrium constant given by the enthalpy and entropy changes (\(ΔH\) and \(ΔS\)) upon desorption:

\(^1\) We used VASP version 5.4.1.

\(^2\) We also performed tests with the (1 × 1 × 1) unit cell relaxing the cell parameters. The volume of the relaxed cell is decreased by 1–4% depending on the considered complex. The adsorption energies are ~0.1 eV lower than for the case with a fixed cell. However, as the Cu loading in our calculations is much higher than in the experiments, the effect of relaxation is most likely overestimated.
\[ K = \frac{k_d}{k_u} = \exp \left( -\frac{\Delta H}{RT} \right) \exp \left( \frac{\Delta S}{R} \right) \]  

(4)

The mass balance in the flowing gas is:

\[ FC_g = -A_0 W \frac{d\theta}{dt} = -\beta A_0 W \frac{d\theta}{dT} \]  

(5)

where \( F \) is the flow rate of the carrier gas, \( A_0 \) is the concentration of the adsorption sites, \( W \) is the zeolite weight and \( \beta \) is the heating rate \( (\Delta T = \beta \delta t) \). The concentration can in this way be written:

\[ C_g = -\frac{\beta A_0 W}{F} \frac{d\theta}{dT} = \frac{\theta}{1 - \theta} \frac{P_0}{RT} \exp \left( -\frac{\Delta H}{RT} \right) \exp \left( \frac{\Delta S}{R} \right) \]  

(6)

The concentration depends on temperature and site-coverage. The site-coverage is obtained iteratively through:

\[ \theta_{i+1} = \theta_i + \left( \frac{d\theta}{dT} \right)_i \Delta T \]  

(7)

This relation connects \( C_g \) and \( T \), which gives the TPD profile.

The calculated NH₃-TPD profiles are compared to experimental data for a Cu-CHA catalyst with Si/Al = 15 and a Cu loading of 2.9 wt% Cu. The NH₃-TPD was measured with a microreactor system, using a 50 mg sample of the catalyst in a quartz U-tube (4 mm inner diameter). The flow rate was 190 Nml/min during the entire procedure. The catalyst was initially reduced in a mixture of 800 ppm NO and 900 ppm NH₃ at 200 °C; under these conditions the [Cu(I)(NH₃)₂]⁺ complex is formed [39]. NO was thereafter removed from the gas phase, and the catalyst was saturated in 900 ppm NH₃ at 200 °C, followed by 2 h purge in N₂ at the same temperature. To measure the NH₃-TPD, the sample was cooled down to 150 °C, and thereafter heated to 550 °C at a rate of 3 °C/min, while the concentration of NH₃ in the reactor exit gas was recorded using a FTIR spectrometer (Gasmet CX4000) connected to the reactor outlet.

### 3 Results and Discussion

The desorption peaks in the TPD-profile are sensitive to the change in free energy \( (\Delta G = \Delta H - T \Delta S) \). The change in entropy \( (\Delta S) \) has been measured to be close to constant \((ca 150 J/K/mol)\) over a wide range of zeolites and experimental conditions [38], therefore we use this value. The change in enthalpy \( (\Delta H) \) is here calculated using DFT. To verify the ability of the current approach to describe the interactions between Cu ions and NH₃, we calculated the sequential NH₃ binding energies of \([Cu(I)(NH₃)ₓ]⁺ (x = 1–4)\) in gas phase. This is a system which has been experimentally investigated by collision-induced dissociation [40]. Our calculated (zero-point corrected) sequential binding energies of \([Cu(I)(NH₃)ₓ]⁺ (x = 1–4)\) are 2.41, 2.58, 0.51 and 0.41 eV, respectively. This is in good agreement with the experimental values of 2.49, 2.60, 0.52 and 0.42 eV [40], indicating that the Cu-NH₃ bond strength is accurately described by PBE+ccx.

For NH₃ adsorption in Cu-CHA, we have considered the species shown in Fig. 1. Figure 1a shows NH₃ adsorbed at a Brønsted acid site forming NH₄⁺ and Fig. 1b-f show the different Cu complexes. The sequential desorption energies are reported in Table 1.

Considering the case with adsorbates in each rhombohedral unit cell \((E_{des}^{1×1×1})\), the energy required for decomposition of NH₃⁺ is calculated to be 1.46 eV, which is within the range \((1.34–1.67 eV)\) measured for the NH₃ adsorption on Brønsted acid sites in H-ZSM-5 [41]. The desorption energies for \([Cu(I)(NH₃)ₓ]⁺\) are 1.29 and 1.54 eV, respectively. The clear separation between the two energies should result in different peaks in the TPD profile. Cu²⁺ is considered with one to four NH₃ ligands. The highest desorption energy is obtained when going from four to three ligands. The sequential desorption energies for the remaining ligands are all lower. Thus, once the decomposition of the \([Cu(II)(NH₃)ₓ]²⁺\) complex starts, all ligands should desorb. The situation is slightly more complex for \([Cu(II)(OH)(NH₃)₁]⁺\) which shows a non-monotonous behaviour with the highest energy calculated for decompositions of the second NH₃. Thus, also this species should give rise to multiple peaks in the TPD profile.

To study the influence of complex and adsorbate concentration, calculations were performed also in a \((2 \times 2 \times 2)\) super-cell. In this case, the Si/Al ratio was reduced by a factor of 8 and adsorption was considered only in one of the eight unit cells. The differences in adsorption energies are small, all being within 0.1 eV. In comparison with the high coverage results, cases with Cu-species not directly bonded to the framework, have slightly lower NH₃ adsorption energies, whereas NH₃ bonded to framework-coordinated Cu ions have slightly higher adsorption energies.

Turning to the TPD profiles, we have simulated desorption curves for some representative cases using the \(E_{des}^{1×1×1}\) energies. Figure 2a shows the desorption profiles for the linear complex. The peak at ca. 350 °C originates from decomposition of \([Cu(I)(NH₃)₂]⁺\), whereas the higher desorption energy for the remaining NH₃ ligand yields a peak at about 460 °C. Figure 2b shows the desorption peaks from \(NH₄⁺\) (Brønsted acid site) and \([Cu(II)(NH₃)₃]²⁺\) at 430 °C and 475 °C, respectively. As the desorption energies of the remaining NH₃ adsorbed on Cu²⁺ are lower than the first, only one peak should appear for this complex.

We compare the simulated TPD profiles with experiments performed for Cu-CHA (Fig. 2c). The experiment was performed with NH₃ adsorbed at 200 °C. The temperature was lowered to 150 °C before starting the TPD measurement. The results show the two features at 290 and
430 °C, respectively. Based on the calculations, we attribute the lower temperature feature to the decomposition of [Cu(I)(NH3)2]+. The feature at higher temperature could be assigned to [Cu(I)NH3]+, Bronsted acid sites (NH4+), and decomposition of [Cu(II)(NH3)2]2+. Previously it has been shown that the stability of the [Cu(I)(NH3)2]+ pairs depends on the local Al-distribution [24]. Similar effects could be anticipated for complexes considered here, which will lead to a broadening of the TPD features. In addition to the Al-distribution, the concentration of species in the zeolite can give rise to a broadening. The difference between the adsorption energies calculated in the (1 × 1 × 1) and the (2 × 2 × 2) cells gives an estimate of such effects.

In the literature, three peaks are generally present in the desorption profile of ammonia from Cu-CHA [8–11]. A low-temperature peak below 200 °C, an intermediate-temperature peak at 250–350 °C and a high-temperature peak at 400–500 °C. The intermediate and high-temperature peaks are present in Fig. 2c. It has been suggested that the low-temperature peak should be assigned to NH3 desorption from Lewis acid sites, the intermediate-temperature peak...
could elucidate the known drop in NH$_3$-SCR activity with increasing temperature at 300–350 °C. The low-temperature activity is governed by the linear complexes which are known to activate oxygen while forming transient pairs [21–24]. Our calculations show that [Cu(I)(NH$_3$)$_4$]$^{+}$ decomposes at temperatures when the loss of activity is observed. The residual [Cu(I)NH$_3$]$^{+}$ species is coordinated to a framework oxygen which hinders activation of O$_2$. Meanwhile, the [Cu(II)(NH$_3$)$_4$]$^{2+}$ complex is still intact and not available for taking part in the catalytic cycle. As the temperature is raised above 350 °C, bare framework coordinated Cu-species are present reactive to oxygen [42]. Thus, NH$_3$ inhibits the SCR reaction in the intermediate temperature regime.

![Fig. 2](attachment:image.png)

**Fig. 2** a, b Simulated desorption curves of NH$_3$ in Cu-CHA. The parents complexes are indicated. Only one adsorption event from each complex is considered. c Experimental NH$_3$-TPD profile after NH$_3$ adsorption in Cu-CHA at 200 °C. The experimental Cu-CHA is prepared with the Si/Al ratio of 15 and the Cu content is 2.6 wt%, which corresponds to a Cu/Al ratio of 0.47. The simulations and experiments are performed with a heating rate of 3 °C/min and a flow rate of 190 Nml/min

peak to Cu-sites and the high-temperature peak to Brønsted acid sites.

Previous thermodynamic analyses [20, 23] together with the present calculations suggest that the three experimentally observed peaks could be attributed to several overlapping features. The low-temperature peak could originate from Lewis acid sites (not analyzed here) and decomposition of [Cu(II)(OH)(NH$_3$)$_3$]$^{+}$. Species that contribute to the intermediate-temperature peak could be the decomposition of the [Cu(I)(NH$_3$)$_2$]$^{+}$ complex and a residual from [Cu(II)(OH)(NH$_3$)$_3$]$^{+}$. The largest overlap is predicted for the high-temperature peak with contributions from Brønsted acid sites (NH$_4^+$), [Cu(I)NH$_3$]$^{+}$ and [Cu(II)(NH$_3$)$_4$]$^{2+}$. The contribution of Cu-species to the high-temperature peak, is consistent with the fact that the weight of this peak increases with Cu loading [8].

In addition to assisting the interpretation of the NH$_3$-TPD, the calculated adsorption energies for Cu$^+$ and Cu$^{2+}$ species
References


